Trusted & Assured Microelectronics (T&AM) Education & Workforce Development (EWD)

SCalable Asymmetric Lifecycle Engagement (SCALE) Overview

Peggy E. Williams, Ph.D. SCALE Defense Agency – Industry Liaison NSWC Crane December 03, 2024

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A ready workforce is required for the U.S. to lead high-performance microelectronics for decades to come



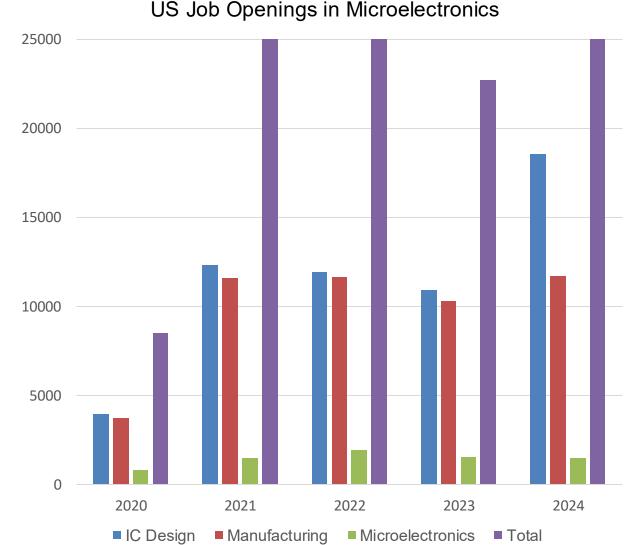


- A skilled technical workforce is required to ensure success of Department of Defense (DoD) modernization initiatives
- National security needs encompass those disciplines with the lowest representation of domestic students
- T&AM has invested in the SCalable Asymmetric Lifecycle Engagement (SCALE) Program to:
 - connect specially trained clearable students with ME defense sector
 - deliver tailored curriculum and provide student access to SOTA tools and processes to produce a more ready workforce
 - scale to meet the national needs; nationally coordinated and regionally executed
- T&AM has invested in Microelectronics (ME) Security Training (MEST) Center to:
 - upskill the existing workforce and improve retention
 - provide DoD personnel access to the newest, cutting-edge microelectronics education and tools from world-class leaders in academia free of charge





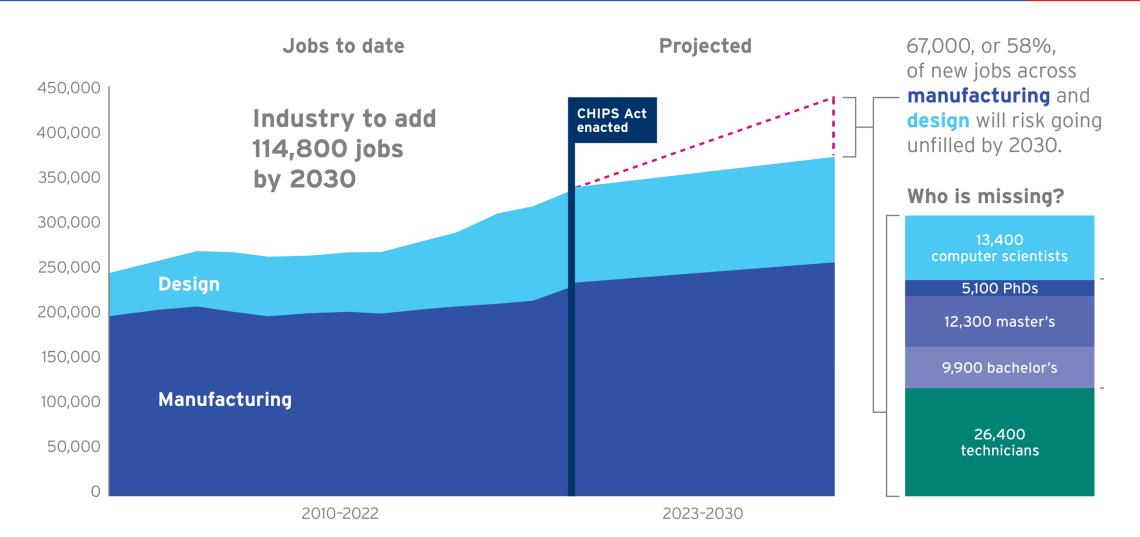
- US demand for microelectronics employees is increasing rapidly, particularly in the public sector
- At same time, the number of students dropped with the pandemic – the Indiana Commission for Higher Education (ICHE) indicated that this was "the lowest rate—and sharpest decline—in at least a generation"





Distribution Statement A: Approved for Public Release by DOPSR case 25-T-1287; Distribution is unlimited Current and Projected Microelectronics Workforce Needs: Industry Projections





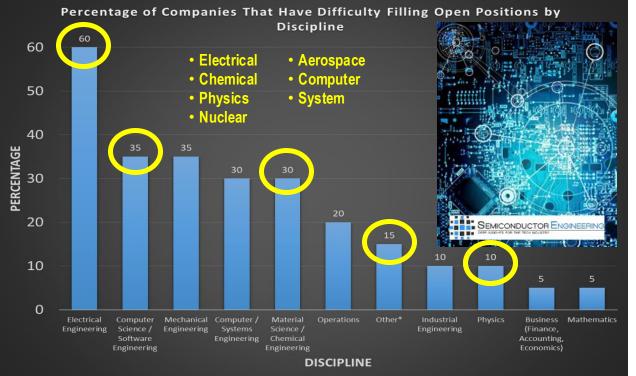
Source: Semiconductor Industry Association, Chipping Away Report, July 2023

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T&AM Education and Workforce Development -What Informs Investments?





State of the Microelectronics Industry

Interdisciplinary & Unique Needs Within a Competitive STEM Market

Global Science & Engineering Indicators

Global Supply of High Demand Engineers Far Outpaces US Supply, Especially From China



NATIONAL SCIENCE BOARD SCIENCE & ENGINEERING INDICATORS 2024

First university degrees in S&E, by selected country: 2011 - 20 2,500 India China 2.000 United States **housands** Brazil 1,500 Mexico China: 33% Engineering BS China – US Δ United Kingdom India: 12% Engineering BS 1,000 France US: 8% Engineering BS —Germany 500 Japan South Korea

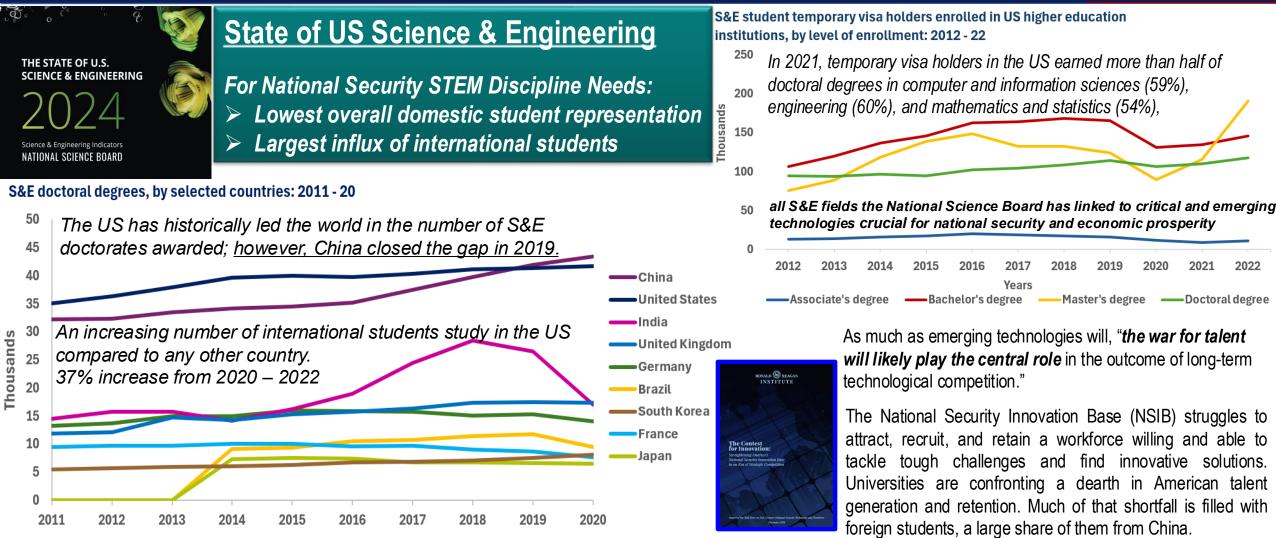
2011 2012 2013 2014 2015 2016 2017 2018 2019 2020 Years

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Turkev



T&AM Education and Workforce Development -What Informs Investments?



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Years



DoD Specific Workforce Needs



DoD and defense industrial base (DIB) have the additional challenges when it comes to competing for talent:

- 1) Workforce must be clearable
 - Universities are confronting a dearth in American talent generation and retention
 - Much of that shortfall is filled with a large share of foreign students from adversarial nations, 25 – 80% depending on degree field and level.¹

¹The Contest for Innovation: Strengthening America's National Security Innovation Base in an Era of Strategic Competition. Report of the Task Force on 21st Century National Security Technology and Workforce. 2019

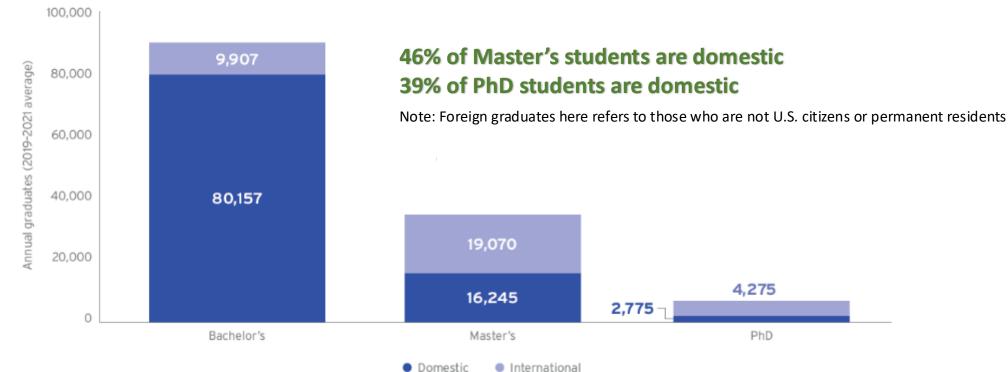


Clearable Workforce



SIA July 2023 Report "CHIPPING AWAY: ASSESSING AND ADDRESSING THE LABOR MARKET GAP FACING THE U.S. SEMICONDUCTOR INDUSTRY"

Annual graduates in semiconductor-related **engineering fields** by degree level and citizenship at U.S. colleges and universities



https://www.semiconductors.org/chipping-away-assessing-and-addressing-the-labor-market-gap-facing-the-u-s-semiconductor-industry/

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- 2) National security interests require a unique blend of skillsets/education
 - Due to unique mission sets, DoD faces challenges in filling roles developing specialized technologies which are not supported by commercial markets
 - For example, DoD has unique workforce needs in radiation hardened microelectronics and other extreme environments, advanced packaging, System on Chip (SOC) Security, etc.

¹The Contest for Innovation: Strengthening America's National Security Innovation Base in an Era of Strategic Competition. Report of the Task Force on 21st Century National Security Technology and Workforce. 2019



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Education & Workforce Development: Mission





Developing the U.S. Defense Microelectronics Workforce





- **Attract** STEM students into T&AM fields of study via replicable, scalable PPAP model
- Ē **Develop** clearable, ME knowledgeable workforce for DoD modernization needs
- (ዮዮዮ) **Maintain** an agile and adaptive workforce that meets current and future DoD needs







Confirmed by DoD ME WD Strategic Plan's prioritized roadmap, the Mission continues

- Outreach for earlier and broader ME <u>exposure</u> including K-12, and veterans.
- Γ, Advance PPAP knowledge sharing education continual improvement, specialized curricula

(<u>~</u>~ **Retain** clearable, dynamic <u>experience</u>d workforce that targets DoD/DIB needs, e.g. RadHard, AI

Data-driven investments based on stakeholder needs

K-12 STEM · Technical Certificates · Undergraduate · Master's · PhD · Existing Workforce · Microelectronics Leadership Distribution Statement A: Approved for Public Release by DOPSR case 25-T-1287; Distribution is unlimited

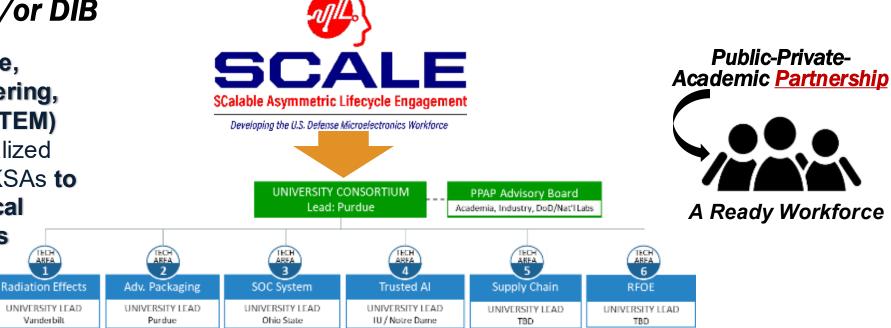


SCalable Asymmetric Lifecycle Engagement



Develop meaningful program for US citizen students to establish relationships with potential employers, which lead to employment after graduation with the US Government and/or DIB

Matching Science, Technology, Engineering, and Mathematics (STEM) students with specialized curricula and relevant KSAs to Gov't/DIB technical workforce needs



<u>Scalable:</u> Extend the program across multiple universities. <u>Replicable:</u> Extend the program across other technology areas. <u>Asymmetric:</u> Produce clearable, knowledgeable workforce <u>Nationally coordinated and regionally executed</u>: network of stakeholders and universities.

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Scope and Technical Objectives

Security. Train students and faculty in ITAR, EAR, CCL, and related regulations and to provide facilities to meet program requirements; security clearances for students.



Curricular innovation. Tailored curriculum and targeted research experiences; designed based on DoD prioritized needs; collaboration between practitioners and educators.



Recruiting. Early exposure to the program including K-12 and community colleges; incentives; identity building through cohorts.



Projects, Research, and Internships. Mentored research experiences; near-peer and DoD/DIB mentoring; internships.

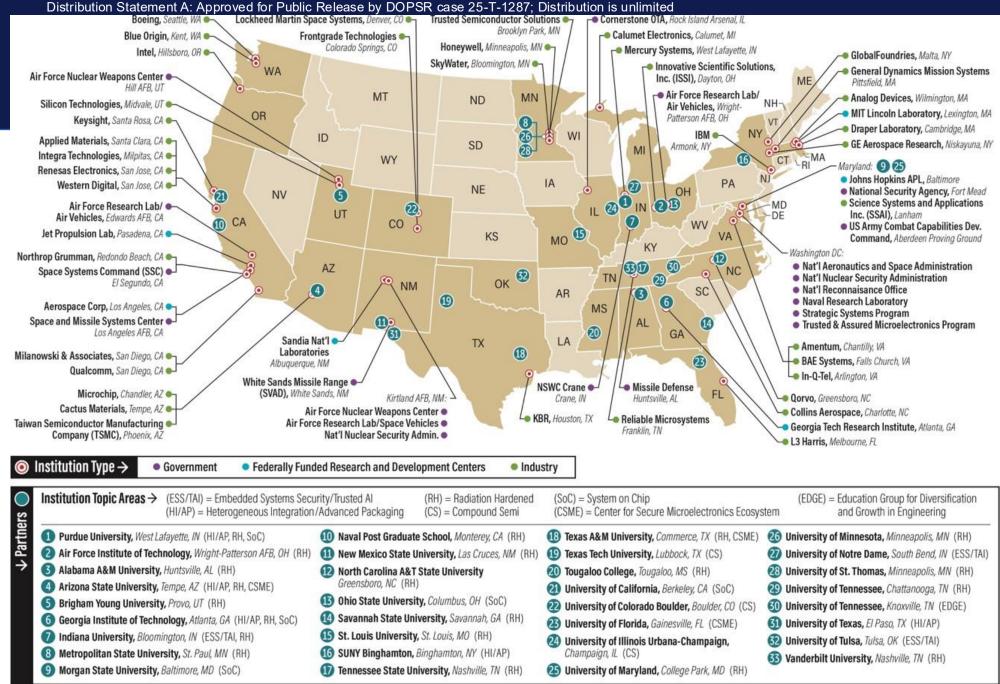


Metrics-driven, iterative model development. Model will be updated through an iterative, design-based method; metrics include both outcome evaluations and process assessments.



SCALE Map

 Growth to 80 Gov/DIB partners
>100 faculty across >30 universities



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Fast Facts on SCALE



Growth	FY20	FY21	FY22	July 2023	Dec 2024
Current	25	191	278	316	705
Total	25	218	385	607	1024

- Over 65% of graduating undergrads entering defense ME sector or went on to graduate school (WIN)
 - vs ~30% non-SCALE students
- 44% SCALE undergraduates went on to graduate school
 - vs ~20% non-SCALE students

	SCALE Totals	RH	HIAP	SOC	AI/ESS
Current students	705	242	172	230	49
Total students	1090	404	255	321	105
Students with internship / research experiences	478	166	110	13	57
Alumni	352	102	50	66	32
Students placed	319	84	43	59	31
Withdrawn	33	18	7	7	1

Over 4000% growth since program inception 4 years ago!

> 96% retention rate in SCALE program

March 2023:
\$160k/student win
ROI = 1.9*
March 2024:

- > \$120k/student win
- ➢ ROI = 2.5

December 2024
ROI = 3.5

*for every \$1 invested, you receive a value of \$2.90 back

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Newest SCALE Initiatives



• Growth in Engineering

- working with *EDucation group for Growth in Engineering* (EDGE) to develop a national education program to attract, educate, train, and retain a broad population in semiconductor sciences and technologies

Veterans

 conducting a study to identify ways to engage with veterans and bring them into ME for DoD/DIB

• K-12 pilot

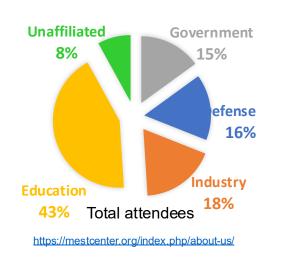
 working with teachers to help them develop modules to teach in their classrooms while providing required professional development and vertical alignment, along with sustainability Distribution Statement A: Approved for Public Release by DOPSR case 25-T-1287; Distribution is unlimited

National Microelectronics Security Training Center (MEST)



Develop and provide training programs on ME design and security to the Gov'n/DIB

- **On-site/online Short-term Training:** MEST faculty and engineers visit org site to provide 3-5 days training on specific topic and award certificates
- Semester Long Courses: In-depth courses spanning several weeks or months, providing thorough understanding of microelectronics/security concepts
- **On-campus Lab Sessions:** Short term (up to two weeks) practical training thru access to Physical Assurance other Hardware Security Labs
- Chip, PCB, and Assembly Design and Fabrication: Comprehensive courses covering the entire process of microelectronics design; from chip-level design to PCB, assembly and fabrication
- Industry Driven Courses: Tailored courses designed/delivered by industry experts
- Continuing Education Seminars: Interactive webinars delivered virtually, offering timely insights and knowledge on microelectronics/security for busy professionals





Number of Webinars Held	50	
Total Webinar Attendees	4,300	
Total Training Attendees	1,506	
Offering	# Hours	
Long courses	21,825	
Short course	2,850	
Tutorial	900	
Webinars	4,000	
Hands-on trainings	2,300	

Online resources using nanoHUB – SCALE & MEST

> Increase interactive

> Repository available

to all SCALE/MEST

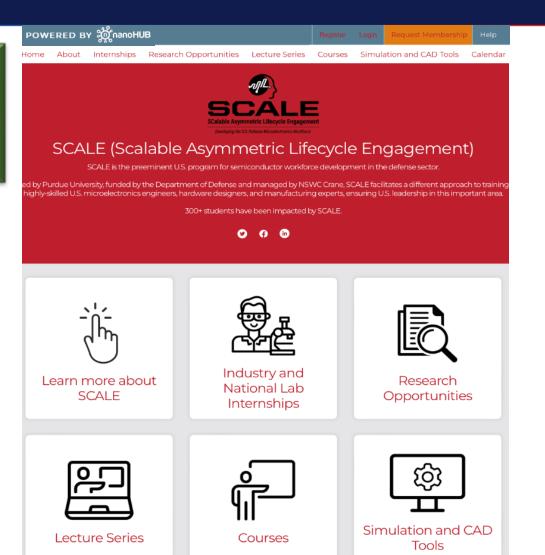
learning

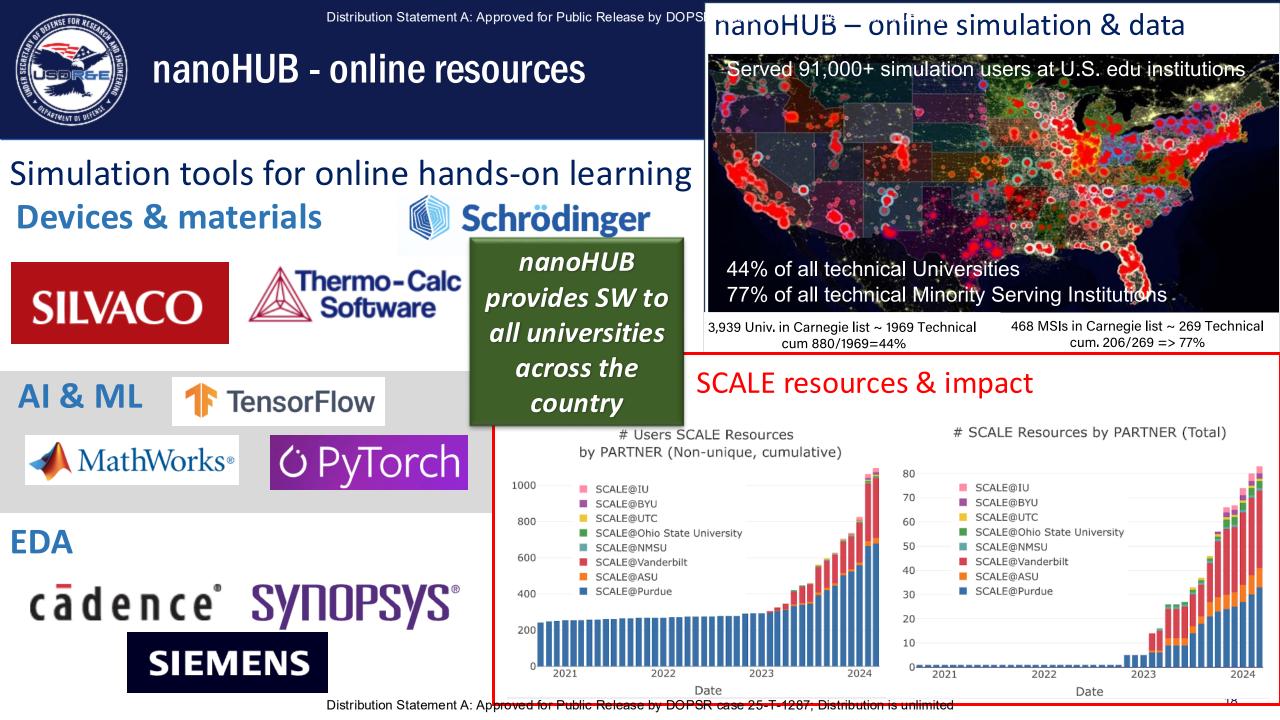
For SCALE students

- Access educational material
- Hands-on learning with online simulations
- Find research opportunities & internships

For SCALE PIs & staff

- Share educational content & events
- Re-use educational content developed by partners
- Control access and collect statistics (data App)
- For DoD and industrial partners
 - Learn about SCALE
 - SCALE impact statistics
 - Share events & opportunities







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How Partners Engage with SCALE Program



Provision of workforce needs and Knowledge, Skills, and Abilities (KSAs)

Participate in data calls, surveys, and/or workshops for KSA updates and needs assessments for relevant technical verticals (biannually)

Provision of SCALE program feedback for continuous improvement

- Engage with career pathways working groups
- >Quarterly touch points

Provision of SCALE employee performance feedback

Participate in data calls and surveys to provide feedback on SCALE student intern or fulltime employee performance for continuous program improvement

Partner organization participation at SCALE events or meetings

- SCALE full program annual meetings
- Technical Vertical annual reviews



How Partners Engage with SCALE Students



Provide internship, co-op, and full-time early career opportunities for SCALE students

- >SCALE Job Board ("passive" job posting system)
- SCALE Web App ("active" can use to proactively reach out to SCALE students of interest)
- Event hosting info sessions, skills workshops, career nights, all can be virtual or inperson depending on objectives

Mentoring

- Serve as a mentor for SCALE Up mentoring circle program, pairing 1-2 mentors with 8-10 students for regular, monthly sessions to discuss career development
- ≻1-semester commitment



Summary

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BACKUP





Scalable Asymmetric Lifecycle Engagement (SCALE) TOPIC AREAS

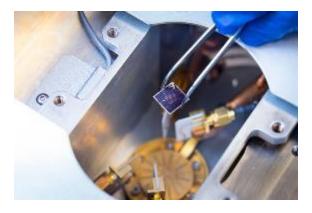
Radiation Hardened Microelectronics

- Radiation in natural and manmade environments can greatly affect the operation and long-term performance of microelectronics
- Radiation hardening is making electronic components and circuits resistant to damage or malfunction caused by high levels of ionizing radiation
- Mitigation approaches include radiation-hardening by process and radiation-hardening by design
- Participating Universities: Vanderbilt, AFIT, St. Louis, Brigham Young, Arizona State University, Georgia Tech, Purdue, NM State, Univ of TN-Chattanooga, Indiana University

System-on-Chip

- Moore's law has led to an exponential increase in the number of devices that can fit onto a single chip
- This has led to a new era where most electronic systems contain chips that integrate various (hitherto discrete) components such as microprocessor, DSPs, dedicated hardware processing engines, memories, and interfaces to I/O devices and off-chip storage
- Designing SoCs is a highly complex process design teams must perform the challenging tasks of developing a functional specification, partitioning and mapping of functions onto hardware components and software, design of a communication architecture to interconnect the components, functional/performance/power analysis and validation, and more
- *Participating Universities:* Ohio State, Georgia Tech, Purdue, UC-Berkeley







Scalable Asymmetric Lifecycle Engagement (SCALE) TOPIC AREAS

Heterogeneous Integration / Advanced Packaging

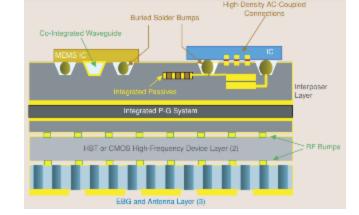
- To keep sizes manageable while improving functionality, complex packaged electronics require similar components to be compressed together horizontally and vertically, and combined with dissimilar components providing complementary functions
- Significant challenges in heterogeneous integration include maintain reliability of connections, managing thermal cycling, and limiting damage from mechanical stress that can cause failures, etc.
- Participating Universities: Purdue, Georgia Tech, SUNY-Binghamton, Arizona State University

Trusted Artificial Intelligence (AI)

- Artificial intelligence (AI) provides a tremendous amount of sophisticated information analysis and decision making capabilities
- Trusted AI requires addressing hard challenges such as verifiability, bias, fairness, explainability, and human interaction and feedback
- Participating Universities: Indiana University, University of Notre Dame, IU-PU Indianapolis

Supply Chain Awareness

- With the increasingly central role of electronic hardware in a broad range of defense applications, securing supplies of electronics is more important than ever before.
- At the same time, exponential growth and complexity in semiconductor manufacturing creates potential supply chain disruption at all levels
- Challenges include understanding potential risks of IP security, measuring and detecting potential tampering with manufacturing and packaging, as well as improving supply chain resilience
- Participating Universities: Purdue, Univ of FL, Georgia Tech, NPS

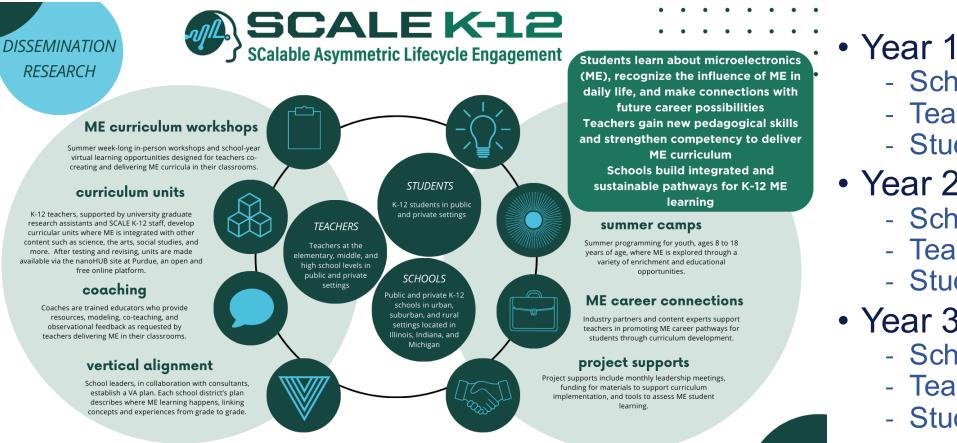






SCALE K-12 Pilot Overview





- School Districts ~ 7
- Teacher Fellows ~ 32
- Students ~ 1,000
- Year 2
 - School Districts ~ 12
 - Teacher Fellows ~ 70+
 - Students ~ 12,000
- Year 3
 - School Districts ~ 12
 - Teacher Fellows ~ 90+
 - Students ~ 19,000

K-12 program reaches ~20,000 students and is self-sustaining after 3.5 years



SCALE / EDGE Consortium



The EDGE Consortium consists of seven top universities led by presidents and deans of engineering. Their goal is to expand the semiconductor workforce to meet economic and security needs.





talent into ME

SCALE / EDGE Pilot



Summary of new programs

Mission and goals: In this 2-year pilot, the EDucation Group for Growth in Engineering (EDGE) will develop a national education program using evidence-based pedagogy and design to attract, educate, train, and retain a broad population in semiconductor sciences and technologies.

EDGE X will attract K-12 students to the semiconductor **Early undergraduate students** K-12 Students workforce. We will work with local affiliates of PBS to develop videos and learning experience materials EDGE X Students often make Students drop out of early relevant to the semiconductor industry. decisions about their STEM courses when they Target audience(s): K-12 students future careers by middle are made to feel they are school not "smart enough." EDGE Academy will educate and retain college students and consist of comprehensive instructor support, EDGE **College students near completion Early/mid-career professionals** including collaborative learning experience redesign, Academy classroom climate evaluation, training, and evaluation. Students may not start More than 50% of Target audience(s): Early undergraduate students workforce entering in the semiconductor microelectronics sector workforce without leave within 5 - 7 years. EDGE Scholars will retain senior-level undergraduate adequate support. and graduate students and early/mid-career professionals EDGE by providing professional development and mentorship. **Scholars Disengaged from higher ed** Increase the size of Target audience(s): Students near completion; early/mid career professionals Most positions in the the talent pool semiconductor industry EDGE Works will train non-college-bound populations don't require a college in skills relevant to the semiconductor industry and will bringing more degree. EDGE consist of industry-driven curriculum and will be disseminated via state-level economic development Works organizations. clearable,skilled Target audience(s): Disengaged from higher ed

Target audiences



EDGE X – Chip Kids

- New web series being co-produced with East Tennessee PBS
 - working to go national in Year 2
- Program aims to ignite passion in STEM disciplines related to the semiconductor industry and motivate all children to see science as an exciting and attainable career path
- Seven episodes for season 1 are nearing completion
 - Season 2 planning in progress
- Host: Alia Pope
 - 4th grade math and science teacher at eSTEM Academy in Little Rock Arkansas
 - @thealiapope has >1M followers across Instagram, Tik tok, Facebook
- Episode 1: https://www.youtube.com/watch?v=c9b SoQgg0-c



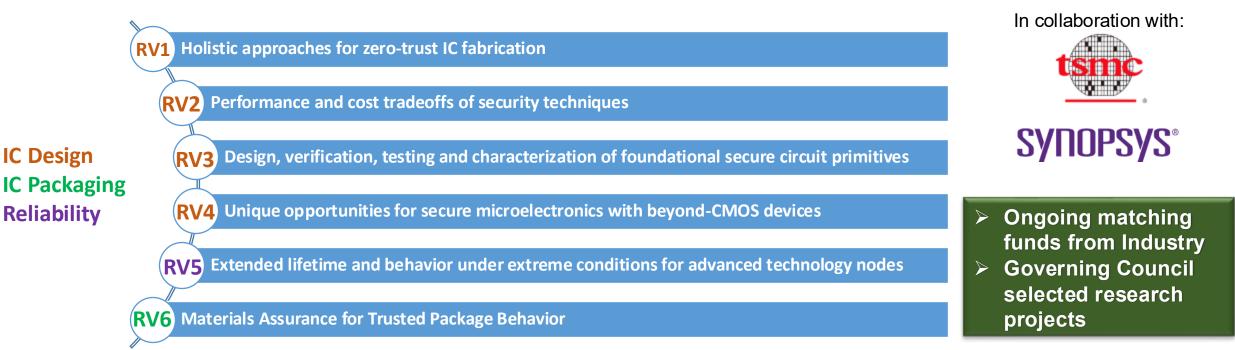




Center for Secure ME Ecosystem (CSME)



 CSME fosters collaboration between industry, academia, and the U.S. government by investigating, designing and evaluating technologies that ensure the security principles of confidentiality, integrity and availability for Integrated Circuit (IC) design, fabrication and packaging while developing the workforce.





Workforce Recommendations for the National Security Commission for Artificial Intelligence (NSCAI)

Recommendations will be incorporated in NSCAI's Q3 report (Sept 2020)

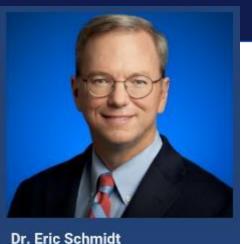
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NSCAI 3rd Quarter Recommendations October 2020

Interim Report and Third Quarter Recommendations







Chairman Vice Chairman Recommendations for the Microelectronics Workforce Prototype, SCALE

"At minimum, **\$24.7 million per year** over the next decade of additional funds are needed to address *each* critical technical area - \$122.36 million per year over the next decade of additional funds are needed to initiate a parallel AI-specific consortium..." https://www.nscai.gov/home Pages 134-136



Projected Yield for 10-YR Investment

Year One

- 1,000 GOV Work Years, at minimum, completing the maximum service agreement of 4:1
- Assume equal number of graduates joining the DIB
- Total: 2,000 Work Years
- Total/Vertical: 400 Work Years

Year Ten

- 10,000 GOV Work Years, at minimum, completing the maximum service agreement of 4:1
- Assume equal number of graduates joining the DIB
- Total: 20,000 Work Years
- Total/Vertical: 4,000 Work Years

*Does not include personnel continuing to work after the 4-year service period.

Year Thirty

- Assume 50% attrition rate after the 4 year service and total service of 30 years for remaining population: 42,500 **GOV Work Years**
- Assume equal number of graduates joining the DIB and same attrition rate
- Total: 85,000 Work Years
- Total/Vertical: 17,000 Work Years

Years 1 - 10

- Incoming employees familiar with applied research that aligns with DoD priorities
- Recruiting advantage through early (K-12) exposure to the program
- Security-policy savvy hires already trained in ITAR, EAR, CCL, and related regulations Assumes Annual Investment Over 10-Years

Assumes 50 Students/Year Per Vertical with a Scholarship for Service Distribution Statement A: Approved for Public Release; Distribution is unlimited.